		Complete if Known			
	Substitute for Form 1449 A & B/PTO	Application Number	10/735,769		
1	OLP E 4 INFORMATION DISCLOSURE	Confirmation Number	3973		
1	STATEMENT BY APPLICANT	Filing Date	December 16, 2003		
9		First Named Inventor	Koichi KAWAMURA		
	JAN 1 1 2006 (use as many sheets as necessary)	Art Unit	1756		
	.8/`	Examiner Name	NOT YET ASSIGNED		
1	(use as many sheets as necessary)	Attorney Docket Number	Q79007		

			U.S. I	PATENT DOCUME	ENTS
F	Cita	Document Number		Publication Date	
Examiner Initials*	Cite No.1	Number	Kind Code ² (if known)	MM-DD-YYYY	Name of Patentee or Applicant of Cited Document
		US			
		US			
		US			

FOREIGN PATENT DOCUMENTS							
Examiner	Cite	Site Foreign Patent Document			Publication Date	Name of Patentee or	Translation ⁶
Initials*	No.1	Country Code ³	Number ⁴	Kind Code ⁵ (if known)	MM-DD-YYYY	Applicant of Cited Document	1 ransiauon
		ЕР	0 809 282	A1	11/26/1997	MAX PLANCK GESELLSCHAFT; CNRS SERVICE DE LA VALORISATIO (FR))	

Examiner Initials*	Cite No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city, and/or country where published.	Translation
		YOSHINOBU TSUJII ET AL.: "Fabrication of patterned high-density polymer graft surfaces. II. Amplification of EB-patterned initiator monolayer by surface-initiated atom transfer radical polymerization", POLYMER, ELSEVIER SCIENCE PUBLISHERS B.V, GB, vol. 43, no. 13, June 2002, pages 3837-3841, XP004349557	
		RAHUL R. SHAH, ET AL., "Using atom transfer radical polymerization to amplify monolayers of initiators patterned by microcontact printing into polymer brushes for pattern transfer", MACROMOLECULES, vol. 33, no. 2, August 1, 2000, pages 597-605, XP002273494	
		KRZYSZTOF MATYJASZEWSKI, et al., "Atom transfer radical polymerization", CHEMICAL REVIEWS, AMERICAN CHEMICAL SOCIETY. EASTON, US, vol. 101, no. 9, December 9, 2001, pages 2921-2990, XP002212148	
		YOUNAN XIA, ET AL., "Soft Lithography", ANGEWANDTE CHEMIE. INTERNATIONAL EDITION, VERLAG CHEMIE. WEINHEIM, DE, vol. 37, 1998, pages 550-575, XP002149045	

		_
Examiner Signature	Date Considered	
DAMILLION OFFICE		_

^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

¹Applicant's unique citation designation number (optional). ²See Kind Codes of USPTO Patent Documents at www.uspto.gov, MPEP 901.04 or in the comment box of this document. ³ Enter Office that issued the document, by the two-letter code (WIPO Standard ST. 3). ⁴For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. ⁵Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST. 16 if possible. ⁶ Applicant is to indicate here if English language Translation is attached.